

光学元件与制造

基于最优化思想的磁流变抛光驻留时间算法

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摘要:

基于最优化思想研究磁流变抛光驻留时间算法。将驻留时间反卷积运算转换成矩阵运算, 以实际加工要求为约束条件, 建立关于驻留时间的最优化数学模型, 利用最小二乘逼近和最佳一致逼近数学解法器对优化模型进行数值求解。仿真结果显示: 该算法收敛幅度大, 计算效率较高, 所求解满足数控加工要求。在自行研制的磁流变抛光机床上进行抛光实验, 对有效口径为50mm的圆形平面工件, 经过4.7min抛光, PV值从0.191λ降至0.087λ, 收敛54.5%, RMS值从0.041λ降至0.010λ, 收敛75.6%。

关键词: 磁流变抛光 驻留时间算法 反卷积 最优化数学模型

Dwell time algorithm based on optimization theory for magnetorheological finishing

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Abstract:

Magnetorheological finishing (MRF) is a deterministic polishing technique capable of rapidly converging to the required surface figure. This process can deterministically control the amount of removed material by varying the time to dwell at each particular position on the workpiece surface. The dwell time algorithm is one of the most important key techniques of the MRF. A dwell time algorithm based on matrix equation and optimization theory was presented in this paper. The previous mathematical model of the dwell time was transferred to a matrix equation containing initial surface error and removal function. The required dwell time was just the solution to the large, sparse matrix equation. A new mathematical model of the dwell time based on the optimization theory was established, which aims to minimize the 2-norm or ∞-norm of the residual error. The solution meets almost all the requirements of precise computer numerical control (CNC) without any need for extra data processing, because this optimization model has taken some polishing condition as the constraints. Practical approaches to find a minimal least-squares solution and a minimal maximum solution are also discussed in the paper. Simulations have shown that the proposed algorithm is numerically robust and reliable. With this algorithm an experiment has been performed on the MRF machine developed by ourselves. After 4.7 minutes'polishing, the figure error of a flat workpiece with a 50mm diameter is improved by PV from 0.191λ to 0.087λ and RMS 0.041λ to 0.010λ. This algorithm can be constructed to polish workpieces of all shapes including flats, spheres, aspheres and prisms.

Keywords: magnetorheological finishing dwell time algorithm deconvolution optimization model

收稿日期 修回日期 网络版发布日期

DOI:

基金项目:

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参考文献:

- [1] POLLICOVE H M, FESS E M. Deterministic manufacturing processes for precision optical surfaces [J]. SPIE, 2003, 5078: 90-96.
- [2] 张峰, 余景池, 张学军, 等. 磁流变抛光技术 [J]. 光学精密工程, 1999, 5(3): 1-8.

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- ZHAN Feng, YU Jing-chi, ZHAN Xue-jun, et al. Magnetorheological finishing technology [J]. *Opticals and Precision Engineering*, 1999, 5(3): 1-8. (in Chinese with an English abstract)
- [3] KORDONSKI W I, JACOBS S D. Magnetorheological finishing [J]. *International Journal of Modern Physics*, 1996, B10: 2837-2848.
- [4] 康桂文. 磁流变抛光技术的研究现状及其发展 [J]. *机床与液压*, 2008(3): 173-175.
- KANG Gui-wen. Research and development of magnetorheological finishing [J]. *Machine Tool & Hydraulics*, 2008(3): 173-175. (in Chinese with an English abstract)
- [5] 李全胜, 成晔, 蔡复之, 等. 计算机控制光学表面成形驻留时间算法研究 [J]. *光学技术*, 1999, 5(3): 56-60.
- LI Quan-sheng, CHENG Ye, CAI Fu-zhi, et al. Dwell time algorithm in computer controlled optical surfacing [J]. *Optical Technique*, 1999, 5(3): 56-60. (in Chinese with an English abstract)
- [6] 俞敏, 杨力, 万勇建. 驻留时间参数优化分析 [J]. *光学与光电技术*, 2006, 2(1): 5-7.
- YU Min, YANG Li, WAN Yong-jian. Optimizing analyse on dwell-time parameters [J]. *Optics & Optoelectronic Technology*, 2006, 2(1): 5-7. (in Chinese with an English abstract)
- [7] 邓伟杰, 郑立功, 史亚莉, 等. 基于线性代数和正则化方法的驻留时间算法 [J]. *光学精密工程*, 2007, 7(7): 1009-1015.
- DENG Wei-jie, ZHENG Li-gong, SHI Ya-li, et al. Dwell time algorithm based on matrix algebra and regularization method [J]. *Optics and Precision Engineering*, 2007, 7(7): 1009-1015. (in Chinese with an English abstract)
- [8] XU Cheng-qi, AISSAOUI I. Algebraic analysis of the Van Cittert iterative method of deconvolution with a general relaxation factor [J]. *Optical Society of America*, 1994, 11: 2804-2808.
- [9] JANSSON P A. Deconvolution of computer controlled polishing [J]. *Applied Optics*, 1977, 6(1): 213-244.
- [10] CARNAL C L, EGERT C M, HYLTON K W. Advanced matrix-based algorithm for ion beam milling of optical components [J]. *SPIE*, 1992, 1752: 54-62.
- [11] ZHOU Lin, DAI Yi-fan, XIE Xu-hui. Model and method to determine dwell time in ion beam figure [J]. *Nanotechnology and Precision Engineering*, 2007, 6(2): 107-112.
- [12] WU Jian-fen, LU Zhen-wu, ZHANG Hong-xin, et al. Dwell time algorithm in ion beam figuring [J]. *Applied Optics*, 2009, 7(10): 3930-3937.
- [13] LEE H, YANG Min-yang. Dwell algorithm for computer-controlled polishing of small axis-symmetrical aspherical lens mold [J]. *Optical Engineering*, 2001, 40(9): 1936-1943.
- [14] 彭小强. 确定性磁流变抛光的关键技术研究 [D]. 长沙: 国防科技大学, 2004.
- PENG Xiao-qiang. Study on the key techniques of deterministic magnetorheological finishing [D]. Changsha: National University of Defense Technology, 2004. (in Chinese)
- [15] 邹谋炎. 反卷积和信号复原 [M]. 北京: 国防工业出版社, 2001.
- ZOU Mou-yan. Deconvolution and signal recovery [M]. Beijing: National Defence Industry Press, 2001. (in Chinese)
- [16] 陈宝林. 最优化理论与算法 [M]. 2版. 北京: 清华大学出版社, 2005.
- CHEN Bao-lin. Optimization theory and algorithms [M]. 2nd ed. Beijing: Tsinghua University Press, 2005.
- [17] COLEMAN T F, LI Y. A reflective newton method for minimizing a quadratic function subject to bounds on some of the variables [J]. *SIAM Journal on Optimization*, 1996, 6(4): 1040-1058.
- [18] GILL P E, MURRAY W, WRIGHT M H. Practical optimization [M]. London: Academic Press, 1981.

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1. 阳志强 郭忠达 陈智利 刘卫国. 一种磁流变抛光方法的探讨[J]. *应用光学*, 2009,30(3): 500-504